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Total Number of Pages: 02

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B.Tech
PEEI5405

8th Semester Regular / Back Examination 2015-16
MICRO ELECTRO MECHANICAL SYSTEMS
BRANCH: AEIE, EIE, IEE, MANUFAC, MANUTECH, MECH
Time: 3 Hours
Max Marks: 70
Q.CODE: W170

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Answer Question No.1 which is compulsory and any five from the rest.
The figures in the right hand margin indicate marks.
Assume suitable values wherever missing

- Q1** Answer the following questions: **(2 x 10)**
- a) What is the range in size of MEMS components? 210
- b) Define the role of sensors and actuators in the context of MEMS. 210
- c) Discuss the properties of materials used in MEMS fabrication. 210
- d) Enumerate the Biomedical Application of MEMS. 210
- e) Why silicon is used in Microsystems? 210
- f) Why is scaling laws important while learning about Microsystems? 210
- g) What is the basic difference between Bulk micromachining and Surface micromachining? 210
- h) Give the applications of bio MEMS and Optical MEMS 210
- i) A plane intercepts the x-, y- and z-planes at 2, 3 and 4 respectively. Obtain the equation for the plane. Write down the Miller indices for this plane. 210
- j) Enlist some single crystal growth techniques. 210
- Q2** a) What are the building blocks of a smart system? **(5)**
What is the purpose of the following smart system components? Also mention their analogous biological system. 210
Sensor
Control System
Data Bus
Actuator
- b) Enlist some two structural and two sacrificial materials. Using any microstructure as an example show the difference between these two materials? **(5)**
- Q3** a) Enlist some techniques employed for thin film deposition. What is spin coating? Use illustrations to aid your answer. **(5)**
- b) What is CVD? Which parameters significantly influence the rate of CVD? Enlist the different types of CVD techniques and mention the typical material deposited using each technique. **(5)**

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- Q4** What are the various steps undertaken in the process of Photolithography. Draw the steps involved in lift-off process of patterning. **(10)**
- Q5** a) Discuss two wafer bonding techniques with suitable illustrations. **(5)**
 b) What are the applications of Micro fluidic systems? What are the advantages of Lab on chip? **(5)**
- Q6** a) What is LIGA? Discuss the LIGA process in detail. Mention some of its applications. **(8)**
 b) If the compliance of a spring is given as 200N/m Calculate the Force required to stretch the spring through a displacement of 40 micrometer. **(2)**
- Q7** a) What is a Beam Splitter? Discuss its operation. **(5)**
 b) Enlist the advantages and application of RF MEMS. **(5)**
- Q8** Write short notes on any two: **(5 x 2)**
- a) Diffusion
 b) LTCC
 c) Issues in packaging
 d) MEMS Gyroscope